



1763

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kuei-Jen Chang

Group Art Unit: 1763

Serial No.: 09/822,749

Examiner: Mulero Luz L. Alejandro

Filed: March 30, 2001

In Response to Office Action
Dated: October 11, 2002For: Method and Apparatus for In-Situ Descum/Hot Bake/Dry
Etch Photoresist/Polyimide Layer

Attorney Docket No.: 67,200-397

#S
125103
NWCertificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

Date: January 10, 2003

Kathy Dixon

RESPONSE TO OFFICE ACTION

Assistant Commissioner
for Patents
Washington, D.C. 20231

Dear Sir:

In response to an Office Action mailed October 11, 2002,
please consider the following remarks.

RECEIVED
JAN 23 2003
TECHNOLOGY CENTER 1700